

 $C_4 H_6 O_2$ 

# VINYL ACETATE MONOMER (VAM)

### **Key features**

- Clear, colorless liquid with a faint ether-like odor
- Key raw material for PVAc, PVOH and VAE emulsions

### **Product description**

**Vinyl acetate monomer (VAM)** is an essential chemical building block used to manufacture a variety of consumer and industrial products.

Vinyl acetate is a colorless liquid with a faint ether-like odor and can be polymerized in mass, solution, suspension or emulsion.

### **Applications**

VAM is the key raw material used for the production of polyvinyl acetate (PVAc), vinyl acetate ethylene (VAE) emulsions and polyvinyl alcohol (PVOH), a precursor to PvB films. VAM is also used to make ethylene vinyl alcohol (EVOH) resins and ethylene- vinyl acetate copolymers (EVA). In addition, VAM is an intermediate used to produce paints and coatings, adhesives, textile finishes, water-soluble films and fibers, and laminated safety glass.



## **Vinyl Acetate Monomer (VAM)**



### **Typical Properties**

#### Unit

Molar mass	g/mol	86.09
Boiling point at 1013 hPa	°C	72.7
Melting point	°C	-93.2
Vapor pressure at 20°C	hPa	119
at 50°C	hPa	445
Vapor density (air = 1)		3.0
Density at 20°C	g/ml	0.932
Solubility in water at 20°C	g/L	20
Evaporation rate (n-butyl acetate = 1)		8.9

Americas: sales-ic-am@celanese.com
Europe: sales-ic-eu@celanese.com
Asia Pacific: sales-ic-aoc@celanese.com
China: sales-ic-cn@celanese.com

### Celanese

222 W. Las Colinas Blvd., Irving, TX 75039 t: +1 877 832 7782 (Technical Service) t: +1 800 845 0940 (Customer Service) w: celanese.com Copyright ©2022 Celanese or its affiliates. All rights reserved.

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